

UNITED STATES DEPARTMENT OF

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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR			ATTORNEY DOCKET NO.
08/726.613	10/07/96	MORI		J	50184
		IM52/0707	٦ [EXAMINER
ROBERT L GOLDBERG				CHU.J	
PO BOX 556 MARLBOROUGH MA 01752				ART UNIT	PAPER NUMBER
MHNEDUKUUGH	MH 01/32	•	·	1752	12
				DATE MAILED:	07/07/99

Please find below and/or attached an Office communication concerning this application or proceeding.

Commissioner of Patents and Trademarks

Application No. 08/726,613

Applicant(s)

Mori et al

Office Action Summary

1

Examiner

John Chu

Group Art Unit 1752

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⊠ Responsive to communication(s) filed on 4/23/99 and 4/26/99	·
★ This action is FINAL.	
 Since this application is in condition for allowance except for for in accordance with the practice under Ex parte Quayle, 1935 C. 	D. 11; 453 U.G. 213.
A shortened statutory period for response to this action is set to ex is longer, from the mailing date of this communication. Failure to reapplication to become abandoned. (35 U.S.C. § 133). Extensions 37 CFR 1.136(a).	espond within the benod for response will cause the
Disposition of Claims	
	is/are pending in the application.
Of the above, claim(s)	is/are withdrawn from consideration.
	is/are allowed.
☐ Claim(s)	is/are objected to.
☐ Claims	_ are subject to restriction or election requirement.
Application Papers	
See the attached Notice of Draftsperson's Patent Drawing Re	eview, PTO-948.
☐ The drawing(s) filed on is/are objected	
☐ The proposed drawing correction, filed on	
☐ The specification is objected to by the Examiner.	
The oath or declaration is objected to by the Examiner.	
Priority under 35 U.S.C. § 119	•
Acknowledgement is made of a claim for foreign priority und	
☐ All ☐ Some* ☐ None of the CERTIFIED copies of the	
received.	
received in Application No. (Series Code/Serial Number	
\square received in this national stage application from the Int	ernational Bureau (PCT Rule 17.2(a)).
*Certified copies not received:	
Acknowledgement is made of a claim for domestic priority to	under 35 U.S.C. § 119(e).
Attachment(s)	
☐ Notice of References Cited, PTO-892	
Information Disclosure Statement(s), PTO-1449, Paper No(s	s). <u>11</u>
☐ Interview Summary, PTO-413	
□ Notice of Draftsperson's Patent Drawing Review, PTO-948	
□ Notice of Informal Patent Application, PTO-152	
SEE OFFICE ACTION ON THE	E FOLLOWING PAGES

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DETAILED ACTION

This Office action is in response to the amendment received April 26, 1999 and the IDS received April 23, 1999.

- 1. The rejected under 35 U.S.C. 103(a) as being unpatentable over Mertens et al is withdrawn based on the amendment to claims 20 and 22. The prior art reference to Mertens lacks a disclosure for a substrate that is an integrated substrate, or a flat panel display as recited in claim 20. Further the photoresist as now claimed in claim 22 defines over the prior art reference to Mertens et al by reciting a photoacid generating compound which is not disclosed in Mertens et al.
- 2. Claims 28-46 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

The claims are recited as dependent on claims 16 and 17. Claims 16 and 17 have been canceled as of the amendment received March 23, 1998 and are not pending.

Claims 24 and 27 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

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- 3. Claims 50-59 are rejected under 35 U.S.C. 112, first paragraph, as based on a disclosure which is not enabling. A development step to form the photoresist relief image is critical or essential to the practice of the invention, but not included in the claim(s) is not enabled by the disclosure. See *In re Mayhew*, 527 F.2d 1229, 188 USPQ 356 (CCPA 1976). It is well known that the formation of photoresist images require an exposure step as well as a development step to reveal the latent image formed in the photoresist layer. Correction is necessary.
- 4. Claims 1, 4-15, 18-20, 22-27 and 47-49 are allowable over the prior art of record.
- 5. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

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6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Examiner Chu whose telephone number is (703) 308-2298. The examiner can normally be reached on Monday - Friday from 9:30 am to 6:00 pm.

The fax phone number for this Group is (703) 305-3599.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the Group receptionist whose telephone number is (703) 308-0661.

John S. Chu

Primary Examiner, Group 1700

J.Chu July 6, 1999